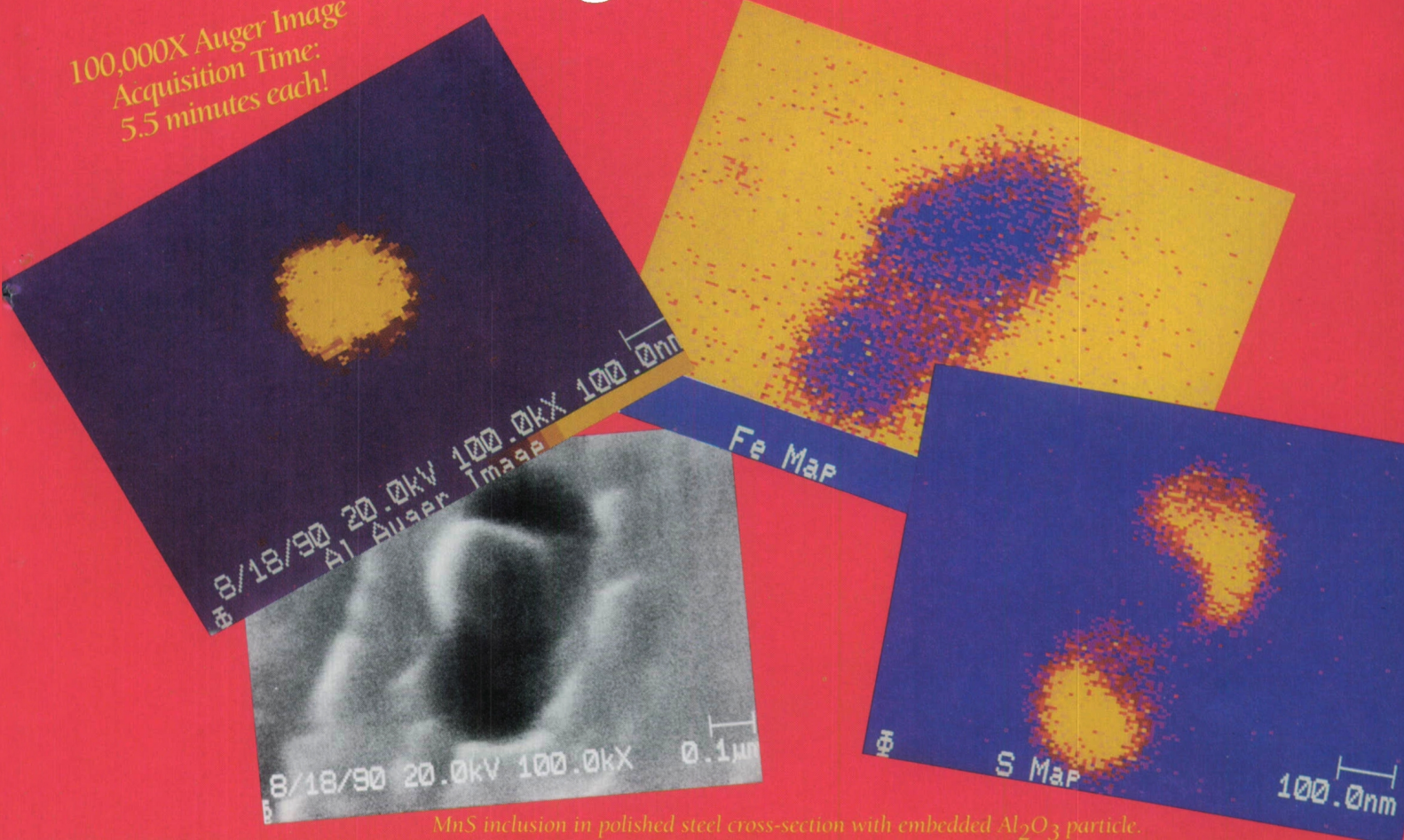


Materials Problem Solving with Auger at 100,000X

100,000X Auger Image
Acquisition Time:
5.5 minutes each!



MnS inclusion in polished steel cross-section with embedded Al₂O₃ particle.

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